

Story of Pinned Buried Photodiode

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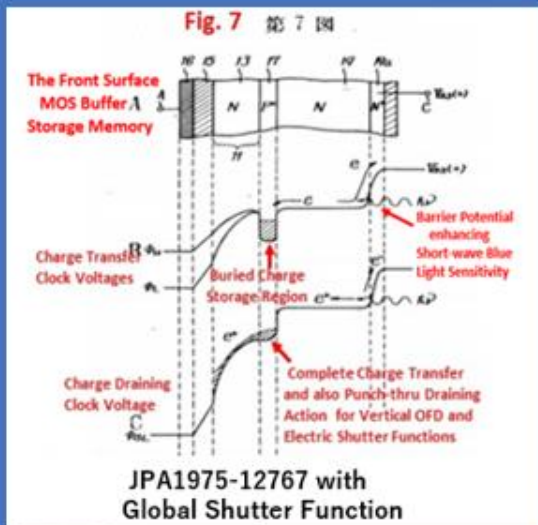
Sony's Representative Inventions Supporting Stacked Multi-Functional CMOS Image Sensors

Sony Corporation
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Pinned Photodiode Adopted for Back-Illuminated CMOS Image Sensors

The history of Sony's inventions of image sensors goes back to the CCD era. Above all, Pinned Photodiode is a technology that contributes to improving the performance of back-illuminated CMOS image sensors, and the history of inventions and product development are as below.

In 1975, Sony invented a CCD image sensor that adopted a back-illuminated N+NP+N junction type and an N+NP+NP junction type Pinned Photodiode (PPD) (Japanese patent application number 1975-127646, 1975-127647 Yoshiaki Hagiwara). In the same year, inspired by such structure, Sony invented a PNP junction type PPD with VOD (vertical overflow drain) function (Japanese Patent No. 1215101 Yoshiaki Hagiwara). After that, Sony succeeded in making a principle prototype of a frame transfer CCD image sensor that adopted the PNP junction type PPD technology, having a high-impurity-concentration P+ channel stop region formed near a light receiving section by ion implantation technology for the first time in the world, and its technical paper was presented at the academic conference, SSDM 1978 (Y. Hagiwara, M. Abe, and C. Okada, "A 380H x 488V CCD imager with narrow channel transfer gates", Proc. The 10th Conference on Solid State Devices, Tokyo, (1978)). In 1980, Sony succeeded in making a camera integrated VTR which incorporated a one-chip frame transfer CCD image sensor that adopted the PNP junction type PPD. President Iwama in Tokyo, Chairperson Morita in New York, at the time held a press conference respectively on the same day, which surprised the world. In 1987, Sony succeeded in developing a 8 mm video camcorder that adopted, for the first time in the world, the interline transfer CCD image sensor, which incorporated "PPD having a high-impurity-concentration P+ channel stop region formed near the light receiving section by ion implantation technology" with VOD function, and became the pioneer of the video camera market. The PPD technology that has been nurtured through such a long history is still used in back-illuminated CMOS image sensors.



Back-illuminated CMOS image sensor

